



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Takeshi OOHASHI et al.**

Group Art Unit: **1752**

Serial No.: **09/926,033**

Examiner: **Yvette C. Thornton**

Filed: **November 7, 2001**

Confirmation No.: **3978**

For: **PHOTOSENSITIVE RESIN COMPOSITION, PHOTOSENSITIVE
ELEMENT USING THE SAME, PROCESS FOR PRODUCING
RESIST PATTERN...**

Attorney Docket Number: **011022**

Customer Number: **38834**

RESPONSE UNDER 37 C.F.R. § 1.111

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Date: March 21, 2005

Sir:

In response to the Office Action dated September 20, 2004, **the response date of which
having been extended by three (3) month to March 20, 2005**, Applicants amend the claims as
follows and submit the following remarks.

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 10 of this paper.